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PROCESS FOR PRODUCTION OF A CARBOXYLIC ACID/DIOL MIXTURE SUITABLE FOR USE IN POLYESTER PRODUCTION

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FIELD OF INVENTION

The present invention relates to a process by which a carboxylic acid/diol mixture is obtained from a carboxylic acid/solvent slurry without isolation of a substantially dry carboxylic acid solid. More specifically, the present invention relates to a process by which a terephthalic acid/diol mixture suitable as a starting material for polyester production is obtained from a terephthalic acid/solvent slurry without isolation of a substantially dry terephthalic acid solid.

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BACKGROUND OF THE INVENTION

Pursuant to the goal of making polyethylene terephthalate(PET) and other polyesters, a great deal of patent literature is dedicated to the describing processes for preparing a carboxylic acid/diol mixture suitable as starting material. In general, these inventions describe specific mixing schemes with a purified terephthalic acid solid and liquid ethylene glycol. Additionally, there is substantial body of literature devoted to producing a purified terephthalic acid in the powder form that is suitable for use in producing PET and other polyesters.

The objective of this invention is to describe a process by which the carboxylic acid/diol mixture suitable as a starting material for polyester

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production is obtained from a carboxylic acid/solvent slurry without isolation of a substantially dry carboxylic acid solid. More specifically, the objective of this invention is to describe a process by which a terephthalic acid/diol mixture suitable as a starting material for polyester production is obtained

5 from a terephthalic acid/solvent slurry without isolation of a substantially dry terephthalic acid solid.

Usually, purified terephthalic acid solid is produced in a multi-step process wherein a crude terephthalic acid is produced. The crude terephthalic acid does not have sufficient quality for direct use as starting

10 material in commercial PET. Instead, the crude terephthalic acid is usually refined to purified terephthalic acid solid.

Liquid phase oxidation of p-xylene produces crude terephthalic acid. The crude terephthalic acid is dissolved in water and hydrogenated for the purpose of converting 4-carboxybenzaldehyde to p-toluic acid, which is a

15 more water-soluble derivative, and for the purpose of converting characteristically yellow compounds to colorless derivatives. Any 4-carboxybenzaldehyde and p-toluic acid in the final purified terephthalic acid product is particularly detrimental to polymerization processes as they act as a chain terminator during the condensation reaction between

20 terephthalic acid and ethylene glycol in the production of PET. Typical purified terephthalic acid contains on a weight basis less than 25 parts per million (ppm) 4-carboxybenzaldehyde and less than 150 ppm p-toluic acid.

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A number of other processes have been developed where a terephthalic acid suitable as starting material for commercial PET production without the use of hydrogenation. Typically, these processes usually involve catalyzed oxidation of p-xylene in an acetic acid solvent
5 followed by filtration and drying of the terephthalic acid from the acetic acid solvent.

To produce a terephthalic acid/diol mixture acceptable for PET production from a terephthalic acid/solvent slurry poses a substantially different problem than from a terephthalic acid and water mixture.

10 Typically, TPA produced via catalyzed oxidation of p-xylene in an acetic acid solvent produces a terephthalic acid/solvent slurry that contains residual catalyst (e.g cobalt, manganese, and bromine). In a common method of producing a substantially dry TPA solid from a terephthalic acid/solvent slurry, the terephthalic acid/solvent slurry is filtered to separate
15 a substantial amount of the acetic acid liquid from the TPA solids. Residual catalyst is usually separated from the terephthalic acid/solvent slurry by washing (rinsing) the wet cake with catalyst-free acetic acid, water or other solvent. The TPA solid is isolated by drying.

In the present invention, a novel process has been discovered
20 resulting in fewer steps than the currently employed processes. The primary utility of the invention is reduction of capital and operating costs associated

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with the isolation of a terephthalic acid powder. In the conventional approach toward producing terephthalic acid via catalyzed oxidation of p-xylene in an acetic acid solvent, a terephthalic acid/solvent slurry is filtered, washed, then dried to produce a terephthalic acid powder suitable as

5 starting material for PET production.

In one embodiment of the present invention, the terephthalic acid/solvent slurry is filtered to produce a terephthalic acid cake with solvent and a TPA solvent mother liquor stream. The terephthalic acid cake with solvent is then washed (rinsed) with water to recover residual metal catalyst

10 material and to produce a water-wet terephthalic acid cake and an TPA solvent/water by-product liquor. The water-wet terephthalic acid cake is then combined with a diol to produce a terephthalic acid/diol mixture suitable as starting material in a commercial PET process. By bypassing conventional processes for isolating a terephthalic acid solid, the equipment

15 necessary produce a terephthalic acid powder is eliminated.

Another surprising and seemingly contradictory aspect of the invention is the benefit of addition of water to the acetic acid and ethylene glycol solvents. In general, in conventional processes for producing terephthalic acid, it is necessary to remove water produced in the oxidation

20 process. Typically, use of acetic acid as an oxidation solvent necessitates an additional process step where acetic acid and water are separated. It is

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seemingly contradictory to produce an acetic acid and water mixture when it can be avoided by drying the terephthalic acid from the acetic acid solvent.

Additionally, in processes for producing PET via esterification of TPA with ethylene glycol, water is generated as a reaction by-product. In
5 general, it is necessary to remove the water produced in the esterification process via an additional process step where ethylene glycol and water are separated. It is seemingly contradictory to produce an ethylene glycol and water mixture when it can be avoided by not introducing water with the TPA.

10 However, the one benefit of this invention is based on the premise that ethylene glycol/water and acetic acid/water separation systems normally exist for conventional TPA and PET production processes. In this invention, the savings associated with eliminating the TPA drying is of greater benefit than the incremental increase in ethylene glycol and water
15 separation capacity plus the incremental increase in acetic acid and water separation capacity.

SUMMARY OF THE INVENTION

20 The present invention relates to a process by which a carboxylic acid/diol mixture is obtained from a carboxylic acid/solvent slurry without isolation of a substantially dry carboxylic acid solid. More specifically, the

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present invention relates to a process for the production of a terephthalic acid/ethylene glycol mixture suitable as feedstock for the production of commercial PET. The resulting process has fewer steps than currently employed processes and can be constructed at lower capital cost.

5 Specifically, the present invention incorporates a direct displacement of water with ethylene glycol. Incorporation of the displacement step eliminates the need to isolate a purified terephthalic acid solid thereby eliminating the need for crystallization, solid-liquid separation, and solids handling equipment normally found in commercial purified terephthalic acid
10 processes.

It is an object of this invention to provide a process for producing a carboxylic acid/diol mixture from a carboxylic acid/solvent slurry without isolation of a substantially dry carboxylic acid solid.

It is another object of this invention to provide a process for
15 producing a terephthalic acid/diol mixture from a terephthalic acid/solvent slurry without isolation of a substantially dry terephthalic acid solid.

It is another object of this invention to provide a process for producing a terephthalic acid/ethylene glycol mixture from a terephthalic acid solvent slurry without isolation of a substantially dry terephthalic acid
20 solid.

It is another object of this invention to provide a process for producing a terephthalic acid/ethylene glycol mixture without isolation of a

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substantially dry terephthalic acid solid by removing water from a water-wet terephthalic acid cake through the use of a carboxylic acid/diol mixing zone.

In a first embodiment of this invention, a process for producing a carboxylic acid/diol mixture is provided comprising the adding a diol to a
5 water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to remove a portion of the water to form the carboxylic acid/diol mixture.

In another embodiment of this invention, a process for producing a carboxylic acid/diol mixture is provided, the process comprising the following steps:

10 (a) removing in a first solid-liquid separation device impurities from a carboxylic acid/solvent slurry to form a carboxylic acid cake with acetic acid and a solvent mother liquor stream.

(b) removing a substantial portion of a solvent in a second solid-liquid separation device from the carboxylic acid cake with acetic acid to
15 form a water-wet carboxylic acid cake and a solvent/water byproduct liquor.

(c) adding a diol to the water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to remove a portion of the water to form the carboxylic acid/diol mixture.

20 In another embodiment of this invention, a process for producing a carboxylic acid/diol mixture is provided, the process comprising the following steps:

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(a) removing a solvent from a carboxylic acid/solvent slurry in a solid-liquid separation zone; wherein a substantial portion of the solvent in the carboxylic acid/solvent slurry is replaced with water to form a water-wet carboxylic acid cake.

- 5 (b) adding a diol to the water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to remove a portion of the water to form the carboxylic acid/diol mixture.

In another embodiment of this invention, a process for producing a terephthalic acid/diol mixture is provided, the process comprising the adding
10 a diol to a water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form the terephthalic acid/diol mixture.

In another embodiment of this invention, a process for producing a terephthalic acid/diol mixture is provided, the process comprising the
15 following steps:

(a) removing in a first solid-liquid separation device impurities from a terephthalic acid/solvent slurry to form a terephthalic acid cake with acetic acid.

- (b) removing a substantial portion of a solvent in a second solid-
20 liquid separation device to form the terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake.

(c) adding a diol to the water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form the terephthalic acid/diol mixture.

In another embodiment of this invention, a process for producing a
5 terephthalic acid/diol mixture is provided, the process comprising the following steps:

(a) removing a solvent from a terephthalic acid/solvent slurry in a solid-liquid separation zone; wherein a substantial portion of the solvent in the terephthalic acid/solvent slurry is replaced with water to form a water-
10 wet terephthalic acid cake.

(b) adding a diol to the water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form the terephthalic acid/diol mixture.

In another embodiment of this invention, a process to produce a
15 carboxylic acid/diol mixture from a carboxylic acid/solvent slurry is provided without the isolation of a substantially dry carboxylic acid solid.

In another embodiment of this invention, a process to produce a terephthalic/diol mixture from a terephthalic acid/solvent slurry is provided, without the isolation of a substantially dry terephthalic acid solid.

20 In another embodiment of this invention a process for producing a terephthalic acid/diol mixture is provided, the process comprising the following steps:

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(a) removing in a first solid-liquid separation device impurities from a terephthalic acid/solvent slurry to form a terephthalic acid cake with acetic acid; wherein the first solid-liquid separation device is operated at a temperature between about 40 °C to about 155 °C .

5 (b) removing a substantial portion of a solvent in a second solid-liquid separation device to form the terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; wherein the second solid-liquid separation device is operated at a temperature between about 40 C to about 155.

10 (c) adding a diol to the water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form the terephthalic acid/diol mixture; wherein the adding occurs at a temperature between about 40 °C and 290 °C; wherein the diol is ethylene glycol.

15 In another embodiment of this invention, a process for producing a terephthalic acid/diol mixture is provided, the process comprising the following steps in the order named:

(a) removing in a first solid-liquid separation device impurities from a terephthalic acid/solvent slurry to form a terephthalic acid cake with
20 acetic acid; wherein the first solid-liquid separation device is operated at a temperature between about 40 °C to about 155 °C .

(b) removing a substantial portion of a solvent in a second solid-liquid separation device to form the terephthalic acid cake with acetic acid

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to form a water-wet terephthalic acid cake; wherein the second solid-liquid separation device is operated at a temperature between about 40 °C to about 155.

(c) adding a diol to the water-wet terephthalic acid cake in a
5 terephthalic acid/diol mixing zone to remove a portion of the water to form the terephthalic acid/diol mixture; wherein the adding occurs at a temperature between about 40 °C and 290 °C; wherein the diol is ethylene glycol.

These objects, and other objects, will become more apparent to
10 others with ordinary skill in the art after reading this disclosure.

DESCRIPTION OF THE INVENTION:

In a first embodiment of this invention shown in figure 1, a process
15 for producing a carboxylic acid/diol mixture **108** is provided, the process comprises adding a diol **107** to a water-wet carboxylic acid cake **106** in a carboxylic acid/diol mixing zone **130** to remove a portion of the water to form the carboxylic acid/diol mixture **108**.

The carboxylic acid/diol mixing zone **130**, the diol **107**, the carboxylic
20 acid/diol mixture **108** and the water-wet carboxylic acid cake **106** is described subsequently in a second embodiment of this invention.

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In the second embodiment of this invention shown in figure 1, a process for producing a carboxylic acid/diol mixture **108** is provided. The process comprises the following steps.

Step (1) comprises removing in a first solid-liquid separation device
5 **110** impurities from a carboxylic acid/solvent slurry **101** to form a carboxylic acid cake with solvent **103** and a solvent mother liquor stream **102**.

Conduit **101** contains a carboxylic acid/solvent slurry comprising a carboxylic acid, impurities and a solvent. The impurities comprises residual catalyst (typically but not limited to cobalt, manganese, or bromine).

10 Suitable solvents include, but are not limited to, aliphatic mono-carboxylic acids, preferably containing 2 to 6 carbon atoms, or benzoic acid and mixtures thereof and mixtures of these compounds with water. Preferably, the solvent is comprised of mainly acetic acid and/or some water. The ratio of acetic acid to water can range from 50:50 to 99:1 acetic acid to water by
15 mass, more preferably in the range of 85:15 to 95:5, and most preferably in the range of 90:10 to 95:5. Suitable carboxylic acids include by are not limited to terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid, and mixtures thereof.

The carboxylic acid/solvent slurry **101** is in the range of 10-40% by
20 weight carboxylic acid. Preferably the carboxylic acid/solvent slurry **101** is in the range of 25- 35% by weight carboxylic acid. Most preferably, the carboxylic acid/solvent slurry **101** is in the range of 30-35% by weight carboxylic acid. The carboxylic acid/solvent slurry in conduit **101** is then

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introduced into a first solid-liquid separation device, **110**, wherein a substantial portion of the solvent mother liquor is recovered in conduit **102**. The solvent mother liquor **102** comprises a substantial portion of the solvent.

5 The first solid-liquid separation device **110** comprises any device capable of efficiently separating solids and liquids. The first solid-liquid separation device **110** can typically be comprised of, but not limited to, the following types of devices: centrifuges, cyclones, rotary drum filters, belt filters, press filters, etc. The first solid-liquid separation device **110** can
10 operate within a temperature range of from approximately 40°C to 155°C. Preferably the first solid-liquid separation device **110** can operate within a temperature range of from approximately 80°C to 150°C. Most preferably the first solid-liquid separation device **110** can operate within a temperature range of from approximately 90°C to 150°C. A carboxylic acid cake with
15 solvent **103**, is produced wherein the moisture composition of the carboxylic acid cake with solvent **103** is in the range of 0.5-30% by weight moisture, preferably in the range of 1-20% moisture, most preferably in the range of 1-5% moisture. Optionally, the residual solvent can be removed by a gas displacement step to minimize solvent contamination with wash.

20 Step (2) comprises removing a substantial portion of a solvent in a second solid-liquid separation device **120** from the carboxylic acid cake with solvent **103** to form a water-wet carboxylic acid cake **106** and a solvent/water byproduct liquor **105**.

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The carboxylic acid cake with solvent **103**, is then subjected to a wash or "rinsing" with water or substantially water with residual amounts of solvent in the solid-liquid separation device, **120**, wherein a substantial portion of the initial solvent is replaced with water to form a water-wet carboxylic acid cake **106**. The water-wet carboxylic acid cake **106**, is preferably in the range of about 0.5-30% moisture, more preferably in the range of 1-20% moisture, and most preferably in the range of 1-5% moisture. The residual moisture of the water-wet carboxylic acid cake **106**, should contain less than about 2% solvent on a mass basis. Additionally, the water-wet carboxylic acid cake should contain less than 1% of any metals (e.g. cobalt, manganese, etc...), typically used as catalysts in p-xylene oxidation, in the slurry mixture in conduit **101**, should remain in the water-wet carboxylic acid cake **106**.

Wash water is introduced into the second solid-liquid separation device **120** via conduit **104**. The wash water should be, on a continuous basis, comprise a mass feed rate in ratio with the solids in **103** in the range of about 0.1:1 to 1.5:1, preferably in the range of 0.1:1 to 0.6:1, most preferably in the range of 0.2:1 to 0.4:1. There are no limitations on the temperature or pressure of the wash water including the use of vaporized water, steam, or a combination of water and steam, as wash.

The second solid-liquid separation device **120** can typically be comprised of, but not limited to, the following types of devices: centrifuges, cyclones, rotary drum filters, belt filters, press filters, etc. The second solid-

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liquid separation device **120** can operate within a temperature range of from approximately 40°C to 155°C. Preferably, the second solid-liquid separation device **120** can operate within a temperature range of from approximately 80°C to 150°C. Most preferably, the second solid-liquid separation device **120** can operate within a temperature range of from
5 about 90°C to 150°C

Optionally, the solvent/water byproduct liquor from the second solid-liquid separation device **105**, is segregated from the solvent mother liquor stream produce by the first solid-liquid separation device **102**.

10 Step (3) comprises adding a diol **107** to the water-wet carboxylic acid cake **106** in a carboxylic acid/diol mixing zone **130** to remove a portion from the water-wet carboxylic acid cake **106** of the water to form the carboxylic acid/diol mixture **108**.

Finally, the water-wet carboxylic acid cake **106**, which is now
15 substantially free of solvent is combined with a diol **107** in a carboxylic acid mixing zone **130**, to form a carboxylic acid/diol mixture **108** suitable for PET production and other polyesters in device **130**. Conduit **109** is used to remove the portion of water from the water-wet carboxylic acid cake **106**. There are no special limitations on the device **130** with the exception that it
20 must provide intimate contact between the water-wet carboxylic acid cake **106**, and the diol **107** to produce a the carboxylic acid/diol mixture **108**.

Examples of such devices include, but are not limited to the following: an agitated vessel, static mixer, screw conveyor, PET esterification reactor(s),

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etc. (Note: a solid eductor could be used to introduce the water-wet carboxylic acid cake into device **130**). Nor is there any specific limitation on the temperature range at which device **130** can operate. However, it is preferable that the temperature of device **130** does not exceed

5 approximately 280°C, temperatures normally found within PET esterification reactors.

The diol in conduit **107** is introduced in such a manner as to displace the water as the dominant slurrying liquid. This can be accomplished by introducing a diol via conduit **107** as a saturated liquid at a temperature

10 which is sufficient to vaporized the water. Preferably, the diol in conduit **107** is introduced as a saturated or superheated vapor. The diol in conduit **107** is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof. Preferably, the diol in

15 conduit **107** is ethylene glycol. Note that within the system shown in figure 1, a substantially dry carboxylic acid solid is not formed. The primary economic advantage in not forming a carboxylic acid dry solid is the elimination of solids handling equipment (e.g. convey systems, silos, etc...).

In a third embodiment of this invention show in figure 1, a process for

20 producing a carboxylic acid/diol mixture **108**, the process comprising the following steps.

Step (1) comprises removing a solvent from a carboxylic acid/solvent slurry **101** in a solid-liquid separation zone **140**; wherein a

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substantial portion of the solvent in the carboxylic acid/solvent slurry **101** is replaced with water to form a water-wet carboxylic acid cake **106**.

In Step (1) the second solid-liquid separation device **120** and the first solid-liquid separation device **110** in the second embodiment of this invention can be combined to form a single device capable of performing both solid-liquid separations. This is shown schematically in figure 1 showing a solid-liquid displacement zone **140** by a dashed outline box around devices **110** and **120**. The removal of the solvent from a carboxylic/solvent slurry **101** in a solid-liquid separation zone **140** to form a water-wet carboxylic acid cake can be accomplished by any means known in the art. The solid-liquid separation zone **140** comprises any device capable of performing both operations of the first solid-liquid separation device **110** and the second solid-liquid separation device **120** described in the second embodiment of this invention. The device in the solid-liquid separation zone **140** can typically be comprised of but not limited to, the following type of devices: centrifuges, cyclones, filters, and such or combination thereof.

Step (2) comprises adding a diol **107** to the water-wet carboxylic acid cake **106** in a carboxylic acid/diol mixing zone **130** to remove a portion of the water to form the carboxylic acid/diol mixture **108**.

Step (2) is identical to step (3) described in the second embodiment of this invention.

In a fourth embodiment of this invention is provided in figure 2, comprises a process for producing a terephthalic acid/diol mixture **208** is

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provided, the process comprises adding a diol **207** to a water-wet terephthalic acid cake **206** in a terephthalic acid/diol mixing zone **230** to remove a portion of the water to form the terephthalic acid/diol mixture **208**.

The terephthalic acid/diol mixing zone **230**, the diol **207**, the
5 terephthalic acid/diol mixture **208** and the water-wet terephthalic acid cake **206** are described subsequently in a fifth embodiment of this invention.

In the fifth embodiment of this invention shown in Figure 2, a process for producing a terephthalic acid/diol mixture **208** is provided. The process comprising the following steps.

10 Step (1) comprises removing in a first solid-liquid separation device **210** impurities from a terephthalic acid/solvent slurry **201** to form a terephthalic acid cake with solvent **203** and a TPA solvent mother liquor stream **202**.

Conduit **201** contains a terephthalic acid/solvent slurry comprising a
15 terephthalic acid, impurities and a solvent. The impurities comprises residual catalyst (typically but not limited to cobalt, manganese, or bromine). Suitable solvents include, but are not limited to, aliphatic mono-carboxylic acids, preferably containing 2 to 6 carbon atoms, or benzoic acid and mixtures thereof and mixtures of these compounds with water.

20 Preferably, the solvent is comprised of mainly acetic acid and/or some water. The ratio of acetic acid to water can range from 50:50 to 99:1 acetic acid to water by mass, more preferably in the range of 85:15 to 95:5, and most preferably in the range of 90:10 to 95:5. The terephthalic acid/solvent

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slurry **201** is in the range of about 10-40% by weight terephthalic acid.

Preferably the terephthalic acid/solvent slurry **201** is in the range of 25-35% by weight terephthalic acid. Most preferably, the terephthalic acid/solvent slurry **201** is in the range of 30-35% by weight terephthalic acid. The

5 terephthalic acid/solvent slurry in conduit **201** is then introduced into a first solid-liquid separation device **210**, wherein a substantial portion of the solvent mother liquor is recovered in conduit **202**. The solvent mother liquor **202** comprises a substantial portion of the solvent.

The first solid-liquid separation device **210** is any device capable of
10 efficiently separating solids and liquids. The first solid-liquid separation device **210** can typically be comprised of, but not limited to, the following types of devices: centrifuges, cyclones, rotary drum filters, belt filters, press filters, etc. The first solid-liquid separation device **210** can operate within a temperature range of from about 40°C to 155°C. Preferably the first solid-
15 liquid device **210** can operate within a temperature range of from approximately 80°C to 150°C. Most preferably the first solid-liquid separation device **210** can operate within a temperature range of from about 90°C to 150°C. A terephthalic acid cake with solvent **203**, is produced wherein the moisture composition of the terephthalic acid cake
20 with solvent is in the range of 0.5-30% moisture, preferably in the range of 1-10% moisture, most preferably in the range of 1-5% moisture. Optionally, the residual solvent can be removed by a gas displacement step to minimize solvent contamination with wash.

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Step (2) comprises removing a substantial portion of a solvent in a second solid-liquid separation device **220** from the terephthalic acid cake with solvent **203** to form a water-wet terephthalic acid cake **206** and a TPA solvent/water byproduct liquor **205**.

5 The terephthalic acid cake with solvent **203**, is then subjected to a wash or "rinsing" with water in the second solid-liquid separation device, **220**, wherein a substantial portion of the initial solvent is replaced with water to form a water-wet terephthalic acid cake **206**. The water-wet terephthalic acid cake **206**, is preferably in the range of 0.5-30% moisture,
10 more preferably in the range of about 1-20% moisture, and most preferably in the range of 1-5% moisture. The residual moisture of the water-wet terephthalic acid cake **206**, should contain less than about 2% solvent on a mass basis. Additionally, the water-wet terephthalic acid cake should contain less than 1% of any metals (e.g. cobalt, manganese, etc...),
15 typically used as catalysts in p-xylene oxidation, in the slurry mixture in conduit **201**, should remain in the water-wet terephthalic acid cake **206**.

Wash water is introduced into device **220** via conduit **204**. The wash water should be, on a continuous basis, comprise a mass feed rate in ratio with the solids in **203** in the range of about 0.1:1 to 1.5:1, preferably in the
20 range of 0.1:1 to 0.6:1, most preferably in the range of 0.2:1 to .4:1. There are no limitations on the temperature or pressure of the wash water including the use of vaporized water, steam, or a combination of water and steam as wash.

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The second solid-liquid separation device **220** can typically be comprised of, but not limited to, the following types of devices: centrifuges, cyclones, rotary drum filters, belt filters, press filters, etc. The second solid-liquid separation device **220** can operate within a temperature range of from
5 about 40°C to 155°C. Preferably, the second solid-liquid separation device **220** can operate within a temperature range of from about 80°C to 150°C. Most preferably, the second solid-liquid separation device **220** can operate within a temperature range of from about 90°C to 150°C.

Optionally, the solvent/water byproduct liquor from the second solid-liquid separation device **205**, is segregated from the solvent mother liquor stream produce by the first solid-liquid separation device **202**.
10

Step (3) comprises adding a diol **207** to the water-wet terephthalic acid cake **206** in a terephthalic acid/diol mixing zone **230** to remove a portion from the water-wet terephthalic acid cake **206** of the water to form
15 the terephthalic acid/diol mixture **208**.

Finally, the water-wet terephthalic acid cake **206**, which is now substantially free of solvent is combined with a diol **207**, to form a terephthalic acid/diol mixture suitable for PET production and other polyesters in device **230**. Conduit **209** is used to remove the portion of
20 water from the water-wet carboxylic acid cake **206**. There are no special limitations on the device **230** with the exception that it must provide intimate contact between the water-wet terephthalic acid cake **206**, and the diol **207** to produce a the terephthalic acid/diol mixture **208**. Examples of such

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devices include, but are not limited to the following: an agitated vessel, static mixer, screw conveyor, PET esterification reactor(s), etc... (Note: a solid eductor could be used to introduce the water-wet terephthalic acid cake into device **230**). Nor is there any specific limitation on the

5 temperature range at which device **230** can operate. However, it is preferable that the temperature of device **230** does not exceed approximately 280°C, temperatures normally found within PET esterification reactors.

The diol in conduit **207** is introduced in such a manner as to

10 displace the water as the dominant slurring liquid. This can be accomplished by introducing a diol via conduit **207** as a saturated liquid at a temperature which is sufficient to vaporized the water. Preferably, the diol in conduit **207** is introduced as a saturated or superheated vapor. The diol in conduit **207** is selected from the group consisting of ethylene glycol,

15 diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof. Preferably, the diol in conduit **207** is ethylene glycol. Note that within the system shown in figure 1, a substantially dry terephthalic acid solid is not formed.

The primary economic advantage in not forming a terephthalic acid dry solid

20 is the elimination of solids handling equipment (e.g. convey systems, silos, etc...).

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In a sixth embodiment of this invention show in figure 2, a process for producing a terephthalic acid/diol mixture **208** is provided. The process comprising the following steps:

Step (1) removing a solvent from a terephthalic acid/solvent slurry **201** in a solid-liquid separation zone **240**; wherein a substantial portion of the solvent in the terephthalic acid/solvent slurry **201** is replaced with water to form a water-wet terephthalic acid cake **206**.

In Step (1) the second solid-liquid separation device **220** and the first solid-liquid separation device **210** in the second embodiment of this invention can be combined to form a single device capable of performing both solid-liquid separations. This is shown schematically in figure 2 showing a solid-liquid displacement zone **240** by a dashed outline box around devices **210** and **220**. The removal of the solvent from a carboxylic/solvent slurry **201** in a solid-liquid separation zone **240** to form a water-wet terephthalic acid cake can be accomplished by any means know in the art. The solid-liquid separation zone **240** comprises any device capable of performing both operations of the first solid-liquid separation device **210** and the second solid-liquid separation device **220** described in the second embodiment of this invention. The device in the solid-liquid separation zone **240** can typically be comprises of but not limited to, the following type of devices centrifuges, cyclones, filters, and such or combination thereof.

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Step (2) comprises adding a diol **207** to the water-wet terephthalic acid cake **206** in a terephthalic acid/diol mixing zone **230** to remove a portion of the water to form the terephthalic acid/diol mixture **208**.

Step (2) is identical to Step (3) described in the fifth embodiment of
5 this invention.

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WE CLAIM:

1. A process for producing a carboxylic acid/diol mixture, said process comprising adding a diol to a water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to remove a portion of the water to form said
5 carboxylic acid/diol mixture.
2. A process according to claim 1 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid, and mixtures thereof.
3. A process according to claim 1 or 2 wherein said diol is selected
10 from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
4. A process according to claim 1 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group
15 consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
5. A process for producing a carboxylic acid/diol mixture, said process comprising the following steps:
 - (a) removing in a first solid-liquid separation device impurities
20 from a carboxylic acid/solvent slurry to form a carboxylic acid cake with acetic acid and a solvent mother liquor stream;

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(b) removing a substantial portion of a solvent in a second solid-liquid separation device from said carboxylic acid cake with acetic acid to form a water-wet carboxylic acid cake and a solvent/water byproduct liquor;

(c) adding a diol to said water-wet carboxylic acid cake in a
5 carboxylic acid/diol mixing zone to remove a portion of the water to form said carboxylic acid/diol mixture.

6. A process according to claim 5 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.

10 7. A process according to claim 5 or 6 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.

8. A process according to claim 5 wherein said diol/carboxylic acid
15 mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

9. A process for producing a carboxylic acid/diol mixture, said process comprising the following steps:

20 (a) removing a solvent from a carboxylic acid/solvent slurry in a solid-liquid separation zone; wherein a substantial portion of the solvent in said carboxylic acid/solvent slurry is replaced with water to form a water-wet carboxylic acid cake.

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(b) adding a diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to remove a portion of the water to form said carboxylic acid/diol mixture.

10. A process according to claim 9 wherein said carboxylic acid is
5 selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic and mixtures thereof.

11. A process according to claim 9 or 10 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol,
10 cyclohexanedimethanol, and mixtures thereof.

12. A process according to claim 9 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

15 13. A process for producing a terephthalic acid/diol mixture, said process comprising adding a diol to a water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form said terephthalic acid/diol mixture.

14. A process according to claim 13 wherein said diol is selected from
20 the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.

15. A process according to claim 13 wherein said diol is ethylene glycol.

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16. A process according to claim 13, 14 or 15 wherein said adding occurs at a temperature between about 40 °C and about 290 °C.

17. A process according to claim 13 wherein said terephthalic acid/diol mixing zone comprises a device selected from the group consisting of an
5 agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

18. A process for producing a terephthalic acid/diol mixture, said process comprising the following steps:

(a) removing in a first solid-liquid separation device impurities
10 from a terephthalic acid/solvent slurry to form a terephthalic acid cake with acetic acid.

(b) removing a substantial portion of a solvent in a second solid-liquid separation device from said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; and

15 (c) adding a diol to said water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form said terephthalic acid/diol mixture.

19. A process according to claim 18 wherein said first solid-liquid separation device is operated at a temperature between about 40 °C to
20 about 155 °C.

20. A process according to claim 19 wherein said second solid-liquid separation device is operated at a temperature between about 40 °C to about 155 °C.

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21. A process according to claim 18 or 20 wherein said adding occurs at a temperature between about 40 °C and about 290 °C.
22. A process according to claim 18 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
23. A process according to claim 18 wherein said diol is ethylene glycol.
24. A process according to claim 18 wherein said terephthalic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
25. A process for producing a terephthalic acid/diol mixture, said process comprising the following steps:
- (a) removing a solvent from a terephthalic acid/solvent slurry in a solid-liquid separation zone; wherein a substantial portion of the solvent in said terephthalic acid/solvent slurry is replaced with water to form a water-wet terephthalic acid cake.
- (b) adding a diol to said water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form said terephthalic acid/diol mixture.
26. A process according to claim 25 wherein said solid-liquid displacement zone is operated at a temperature between about 40 °C to about 155 °C.

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27. A process according to claim 25 wherein said adding occurs at a temperature between about 40 °C and 290 °C.

28. A process according to claim 25 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol,
5 cyclohexanedimethanol, and mixtures thereof.

29 A process according to claim 25 wherein said diol is ethylene glycol.

30. A process according to claim 25 wherein said diol/terephthalic acid mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification
10 reactor.

31 A process to produce a carboxylic acid/diol mixture from a carboxylic acid/solvent slurry without the isolation of a substantially dry carboxylic acid solid.

15 32. A process to produce a terephthalic/diol mixture from a terephthalic acid/solvent slurry without the isolation of a substantially dry terephthalic acid solid.

33. A process for producing a terephthalic acid/diol mixture, said process comprising the following steps:

20 (a) removing in a first solid-liquid separation device impurities from a terephthalic acid/solvent slurry to for a terephthalic acid cake with acetic acid; wherein said first solid-liquid separation device is operated at a temperature between about 40 °C to about 155 °C .

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(b) removing a substantial portion of a solvent in a second solid-liquid separation device to form said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; wherein said second solid-liquid separation device is operated at a temperature between about 40 °C to
5 about 155 °C.

(c) adding a diol to said water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form said terephthalic acid/diol mixture; wherein said adding occurs at a temperature between about 40 °C and 290 °C; wherein said diol is ethylene
10 glycol.

34. A process for producing a terephthalic acid/diol mixture, said process comprising the following steps in the order named:

(a) removing in a first solid-liquid separation device impurities from a terephthalic acid/solvent slurry to form a terephthalic acid cake with
15 acetic acid; wherein said first solid-liquid separation device is operated at a temperature between about 40 °C to about 155 °C ;

(b) removing a substantial portion of a solvent in a second solid-liquid separation device to form said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; wherein said second solid-liquid
20 separation device is operated at a temperature between about 40 °C to about 155 °C; and

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- (c) adding a diol to said water-wet terephthalic acid cake in a terephthalic acid/diol mixing zone to remove a portion of the water to form said terephthalic acid/diol mixture; wherein said adding occurs at a temperature between about 40 °C and 290 °C; wherein said diol is ethylene glycol.
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